



# ENGR 305

MOSFET Circuits at DC

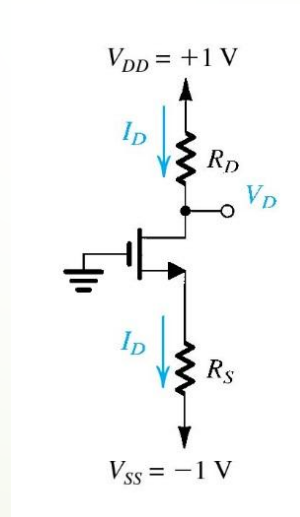
September 30, 2025

# MOSFET Circuits at DC

- ▶ We now look at some examples involving only dc voltages and currents.
- ▶ To keep matters simple we will generally neglect channel-length modulation in the examples.
- ▶ Will work in terms of the overdrive voltage
  - ▶  $V_{OV} = V_{GS} - V_{tn}$  for NMOS
  - ▶  $|V_{OV}| = V_{SG} - |V_{tp}|$  for PMOS
- ▶ Since we are dealing with dc quantities, we will use uppercase symbols with uppercase subscripts for all currents and voltages.

## Example 5.3

- Design the circuit shown; determine the values of  $R_D$  and  $R_S$  so that the transistor operates at  $I_D = 0.2 \text{ mA}$  and  $V_D = +0.2 \text{ V}$ . The NMOS transistor has  $V_t = 0.5 \text{ V}$ ,  $\mu_n C_{ox} = 400 \mu\text{A}/\text{V}^2$ ,  $L = 0.5 \mu\text{m}$ , and  $W = 15 \mu\text{m}$ . Neglect the channel length modulation effect (i.e., assume that  $\lambda = 0$ ).



## Example 5.3

- In order for  $V_D$  to equal +0.2 V at the drain, we must select  $R_D$  as follows:

- $R_D = \frac{V_{DD} - V_D}{I_D} = \frac{1 - 0.2}{0.2 \text{ mA}} = 4 \text{ k}\Omega$

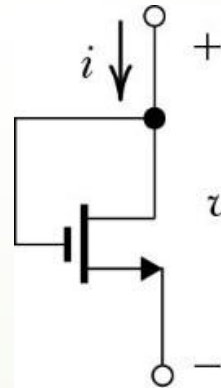
- In order to determine the value for  $R_S$ , we need to know the voltage at the source. This can be found if we know  $V_{GS}$ .
- We note that since  $V_D$  is greater than  $V_G = 0$ , the NMOS transistor is operating in the saturation region.
- We use the saturation-region expression of  $i_D$  to find the required value of  $V_{OV}$ 
  - $I_D = \frac{1}{2} \mu_n C_{ox} \frac{W}{L} V_{OV}^2$

## Example 5.3

- Substituting  $I_D = 0.2 \text{ mA} = 200\mu\text{A}$ ,  $\mu_n C_{ox} = 400\mu\text{A}/\text{V}^2$  and  $W/L = 15/0.5$ ,
  - $200 = \frac{1}{2} \times 400 \times \frac{15}{0.5} V_{OV}^2$
  - This gives  $V_{OV} = 0.18 \text{ V}$
- Then,  $V_{GS} = V_t + V_{OV} = 0.5 + 0.18 = 0.68 \text{ V}$
- We see that the gate is grounded and the source must be at  $-0.68 \text{ V}$ .
- The required value of  $R_S$  can be determined from
  - $R_S = \frac{V_S - V_{SS}}{I_D} = \frac{-0.68 - (-1)}{0.2 \text{ mA}} = 1.6 \text{ k}\Omega$

## Example 5.4

- ▶ The figure shows an NMOS transistor with its drain and gate terminals connected together. Find the  $i - v$  relationship of the resulting two-terminal device in terms of the MOSFET parameters  $k_n = k'_n(W/L)$  and  $V_{tn}$ . Neglect channel-length modulation. Note that this two-terminal device is known as a **diode-connected transistor**.



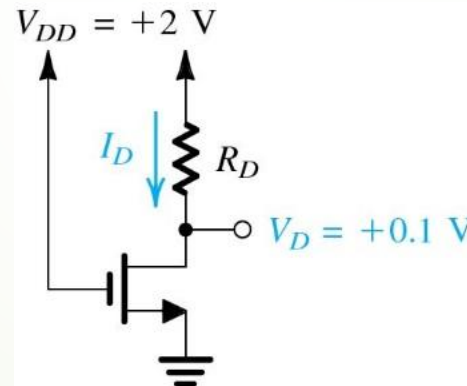
## Example 5.4

- ▶ We first determine in which region the MOSFET is operating. Since  $v_D = v_G$ , operation is in the saturation mode.
  - ▶  $i_D = \frac{1}{2} k'_n \left( \frac{W}{L} \right) (v_{GS} - V_{tn})^2$
- ▶ Now  $i = i_D$  and  $v = v_{GS}$  and
  - ▶  $i = \frac{1}{2} k'_n \left( \frac{W}{L} \right) (v - V_{tn})^2$
- ▶ Replacing  $k'_n \left( \frac{W}{L} \right)$  by  $k_n$  results in
  - ▶  $i = \frac{1}{2} k_n (v - V_{tn})^2$



## Example 5.5

- Design the circuit to establish a dc drain voltage of 0.1 V. What is the effective resistance between drain and source at this operating point? Let  $V_{tn} = 0.5V$  and  $k'_n(W/L) = 2mA/V^2$





## Example 5.5

- ▶ Since the drain voltage is lower than the gate voltage by 1.9 V and  $V_{tn} = 0.5 \text{ V}$ , the MOSFET is operating in the triode region.
- ▶ The drain current is given by
  - ▶  $I_D = k'_n \frac{W}{L} \left[ (V_{GS} - V_{tn})V_{DS} - \frac{1}{2}V_{DS}^2 \right]$
  - ▶  $I_D = 2 \times \left[ (2 - 0.5) \times 0.1 - \frac{1}{2} \times 0.01 \right] = 0.29 \text{ mA}$
- ▶ The required value for  $R_D$  can be found as
  - ▶  $R_D = \frac{V_{DD} - V_D}{I_D} = \frac{2 - 0.1}{0.29} = 6.55 \text{ k}\Omega$
- ▶ In a practical discrete-circuit design problem, one selects the closest standard value available for, say, 5% resistors – in this case,  $6.8 \text{ k}\Omega$ .

## Example 5.5

- ▶ Since the transistor is operating in the triode region with a small  $V_{DS}$ , the effective drain-to-source resistance can be determined as follows:

- ▶  $r_{DS} = \frac{V_{DS}}{I_D} = \frac{0.1 \text{ V}}{0.29 \text{ mA}} = 345 \Omega$

- ▶ Alternately, we can determine  $r_{DS}$  by using the formula

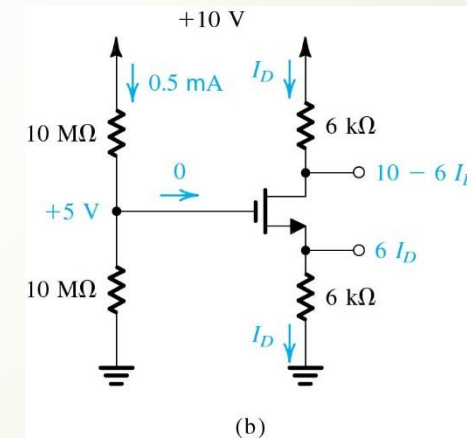
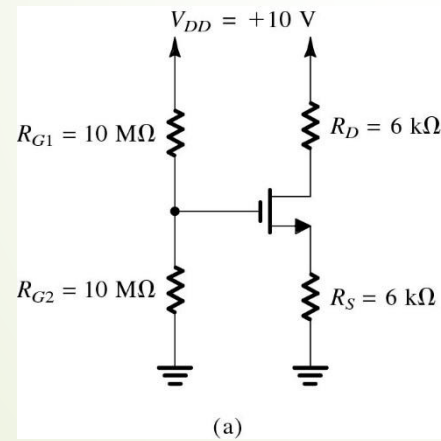
- ▶  $r_{DS} = \frac{1}{k_n V_{OV}}$  to obtain

- ▶  $r_{DS} = \frac{1}{2 \times (2 - 0.5)} = 0.333 \text{ k}\Omega = 333 \Omega$

- ▶ This is close to the value found above.

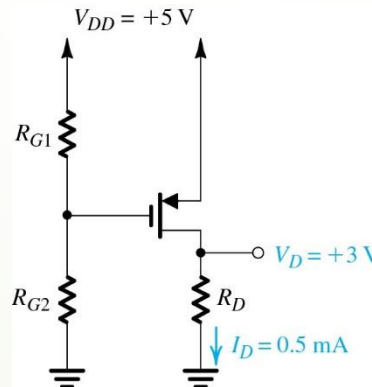
## Example 5.6

- Analyze the circuit shown to determine the voltages at all nodes and the currents through all branches. Let  $V_{tn} = 1\text{ V}$  and  $k'_n(W/L) = 1\text{ mA/V}^2$ . Neglect the channel-length modulation effect ( $\lambda = 0$ ).



## Example 5.7

- Design the circuit shown so that the transistor operates in saturation with  $I_D = 0.5 \text{ mA}$  and  $V_D = +3 \text{ V}$ . Let the PMOS transistor have  $V_{tp} = -1 \text{ V}$  and  $k'_p(W/L) = 1 \text{ mA/V}^2$ . Assume  $\lambda = 0$ . What is the largest value that  $R_D$  can have while maintaining saturation-region operation?



## Example 5.8

- ▶ The NMOS and PMOS transistors in the circuit shown are matched, with  $k'_n(W_n/L_n) = k'_p(W_p/L_p) = 1 \text{ mA/V}^2$  and  $V_{tn} = -V_{tp} = 1 \text{ V}$ . Assuming  $\lambda = 0$  for both devices, find the drain currents  $I_{DN}$  and  $I_{DP}$ , as well as the voltage  $V_O$ , for  $V_I = 0 \text{ V}$ ,  $+2.5 \text{ V}$ , and  $-2.5 \text{ V}$ .

